



- 1 *Lighting*
 2 *Kitchen*
 3 *Indoor interior*

TRANSPARENT, SCRATCH-RESISTANT LAYERS ON LARGE AREA SUBSTRATES

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Technology

- high-rate electron beam evaporation
- plasma-activation by hollow cathode arc discharge (HAD process)
- organic modification by combination with PECVD
- high deposition rates on large areas (50 ... 600 nm/s)
- high productivity – low cost
- low thermal load (plastic, e.g. PC, max. temperature < 130°C)
- wet chemical cleaning (metals prior vacuum processing)
- (pulse) plasma pre-treatment
- technology development to customized requirements
- pilot production for metal strips, plastic films (300 mm width) and large sheets (500 mm × 500 mm) in large scale pilot plant MAXI

Applications

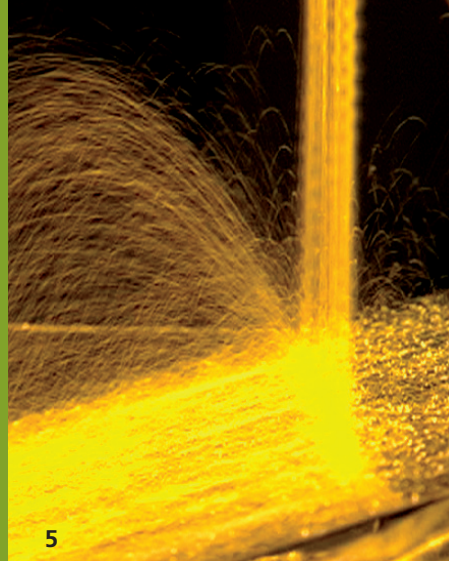
- kitchen
- indoor interior
- architecture
- automotive
- rail-bound transportation
- lighting
- solar thermal absorber
- photovoltaic

Substrates

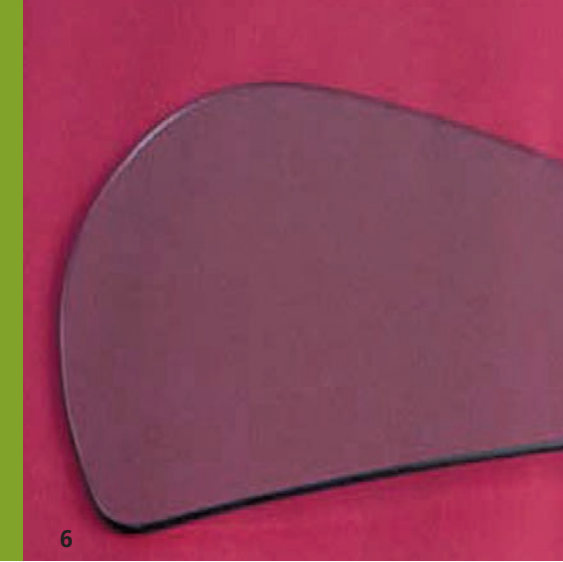
- materials:
 - plastics (e.g. polycarbonate),
 - metals (e.g. stainless steel),
 - glasses (e.g. float glass),
 - ceramics (e.g. tiles)
- shape:
 - small, medium size and large area flat substrates (sheets, strips, films)
 - simple shaped 3D substrates



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Characteristics

Transparent, scratch-resistant layers on large area substrates from plastics, metals, glasses and ceramics.

The optical appearance of the surface will not be altered by coating.

Layers:

- silica based (SiO_x) and alumina based (Al_2O_3) coatings
- thickness 1 ... 10 μm
- organic modification by incorporation of carbon
- improved elasticity
- incorporation of nano-crystalline Si in the SiO_x layer matrix for extremely high hardness

Mechanical properties:

- high hardness (2 ... 15 GPa) compared to substrate (see table)
- high abrasion resistance (see graph, fig. 7)
- excellent adhesion, even in the presence of moisture (plastic substrates)
- low internal stress
- elastic and plastic deformability up to 3%
- stability against temperature cycling
- high corrosion resistance
- low finger print sensibility

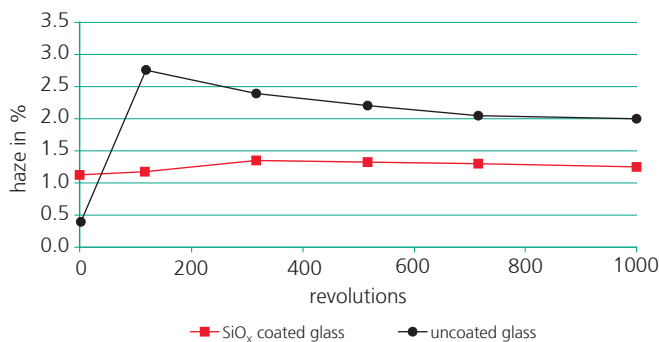
Hardness of substrates and abrasion-resistant SiO_x layers		
Substrate	Hardness of the substrate [GPa]	Hardness of the SiO_x layers [GPa]
Polycarbonate	0.11*	2 ... 3
PET	0.15*	2 ... 3
PMMA	0.18*	2 ... 3
Ferritic steel (St 14)	ca. 1	8 ... 15
High-alloy steel (X5 CrNi 18.10)	3 ... 4	8 ... 15
Float glass	ca. 6	8 ... 10

Hardness measurement by nano-indentation; * Ball indentation

Optical properties:

- high transparency (k: 0.001 ... 0.01 @ 550 nm)
- high uniformity of layer thickness

7 Transparent, hard (ca. 9 GPa) SiO_x layers on glass substrates subjected to the Taber Abraser test. Parameters: Friction wheels CS-10F, 500 g load



- 4 Indoor interior
- 5 High abrasion resistance
- 6 Automotive



We focus on quality and the ISO 9001.